

<b>U.S. DEPARTMENT OF COMMERCE</b> <b>PATENT AND TRADEMARK OFFICE</b>  <b>INFORMATION DISCLOSURE CITATION</b> <i>(Use several sheets if necessary)</i>				ATTY. DOCKET NO.  BDL-487XX		APPLICATION NO.  <b>10/549444</b>	
				APPLICANT: Eric Sion et al.			
				FILING DATE Herewith		TC ART UNIT	
<b>U.S. PATENT DOCUMENTS</b>							
EXAMINER INITIAL		DOCUMENT NUMBER	PUBLICATION/ ISSUE DATE	NAME	CLASS	SUBCLASS	FILING DATE
		US 6,001,419	12/14/1999	Leluan et al. [Delperier]			
		US					
		US					
		US					
		US					
<b>FOREIGN PATENT DOCUMENTS</b>							
		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION YES      NO
		WO 96/15285	5/23/1996	WIPO			X
<b>OTHER DOCUMENTS</b> <i>(including Author, Title, Date, Pertinent Pages, etc.)</i>							
		Glasier, G.F. et al: "Formation of pyrolytic carbon during the pyrolysis of ethane at high conversions," CARBON, Elsevier Science Publishing, New York, NY, vol. 39, no.1, pages 15-23 (January 2001).					
		Becker, A., et al: "Chemistry and kinetics of chemical vapor deposition of pyrocarbon—II pyrocarbon deposition from ethylene, acetylene and 1,3-butadiene in the low temperature regime," CARBON, Elsevier Science Publishing, New York, NY, vol. 36, no. 3, pages 177-199 (1998).					
		Delhaes, P.: "Chemical vapor deposition and infiltration processes of carbon materials," CARBON, Elsevier Science Publishing, New York, NY, vol. 40, no. 5, pages 641-657 (April 2002).					
<b>EXAMINER</b>				<b>DATE CONSIDERED</b>			
*EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.							

CLG/mc/326695-1

**REFERENCES FURNISHED BY INTERNATIONAL BUREAU (PCT/FR2004/001009)**